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PATENT APPLICATION

**RESPONSE UNDER 37 CFR §1.116
EXPEDITED PROCEDURE
TECHNOLOGY CENTER ART UNIT 2828**

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12/14/05

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Daniel KOPF et al.

Group Art Unit: 2828

Application No.: 10/006,396

Examiner: D. NGUYEN

Filed: December 10, 2001

Docket No.: 111399

**For: HIGH POWER AND HIGH GAIN SATURATION DIODE PUMPED LASER MEANS
AND DIODE ARRAY PUMPING DEVICE**

AMENDMENT AFTER FINAL REJECTION UNDER 37 CFR §1.116

**Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450**

Sir:

**In reply to the August 25, 2005 final Office Action and in view of the November 22,
2005 personal interview, please consider the following:**

Amendments to the Claims as reflected in the listing of claims; and

Remarks.